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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/835,643	04/17/2001	Kie Y. Ahn	M4065.0383/P383	4830
24998	7590	07/27/2005	EXAMINER	
DICKSTEIN SHAPIRO MORIN & OSHINSKY LLP			ANDUJAR, LEONARDO	
2101 L Street, NW			ART UNIT	
Washington, DC 20037			PAPER NUMBER	
			2826	

DATE MAILED: 07/27/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	09/835,643	AHN ET AL.	
	Examiner	Art Unit	
	Leonardo Andújar	2826	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 04/25/2005.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1,3-44 and 92-110 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☒ Claim(s) 4-9,12-44 and 92-110 is/are allowed.
- 6) ☒ Claim(s) 1,3,10 and 11 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on _____ is: a) ☐ approved b) ☐ disapproved by the Examiner.
- If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

- 13) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
- a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) Paper No(s). _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____ | 6) <input type="checkbox"/> Other: |

DETAILED ACTION

Acknowledgment

1. The amendment filed on 04/25/2005 in response to the Office action mailed on 03/23/2005 has been entered. The present Office action is made with all the suggested amendments being fully considered. Accordingly, pending in this Office action are claims 1, 3-44 and 92-110.

Claim Rejections - 35 USC § 103

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

3. Claims 1, 3 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hu et al (cited by Applicant) in view of Solon Spiegel (cited by applicant) further in view of Wolf.

4. Hu discloses a method of manufacturing a coplanar wave guide comprising the acts of: forming a signal conductor line over a substrate; forming two longitudinal ground conductor planes over the substrate and opposing sides of the signal conductor line, the ground conductor planes being spaced from the signal conductor line and subsequently forming a trench in the substrate in an area between at least one of the ground conductor planes and the signal conductor line (page 736, col. 1). Hu does not disclose the step of depositing an insulating material on the substrate and the step of forming the

signal conductor line and the ground conductor planes on top of the insulating layer. Nevertheless, Spiegel teaches a method of forming a coplanar waveguide including the step of forming an insulating material (e.g. silicon nitride or silicon oxide) on the substrate and the step of forming the signal conductor line and the ground conductor planes on top of the insulating layer. According to Spiegel, this type of embodiment increases the effective substrate conductivity, which provides a wide band microwave (page 1673; col. 2/lls. 38-46 and page 1677; col. 2/lls. 17-26). Wolf teaches that silicon oxide can be deposited in order to obtain an oxide layer having uniform thickness, and composition, low particulate and chemical contamination, good adhesion to the substrate, low stress to prevent cracking and good integrity for high dielectric breakdown (pg. 183, pp. 1 & table 2). It would have been obvious to one of ordinary skill in the art at the time the invention was made to include the step of forming an insulating material such as silicon oxide on the substrate disclosed by Hu and to form the signal conductor line and the ground conductor planes on top of the insulating layer as suggested by Spiegel to increase effective substrate conductivity and to provide a wide microwave band and to form the silicon oxide disclosed by Hu in view of Spiegel by CVD in order to obtain an oxide layer having uniform thickness and composition, low particulate and chemical contamination, good adhesion to the substrate, low stress to prevent cracking and good integrity for high dielectric breakdown as taught by Wolf.

5. Regarding claim 11, Hu teaches the step of forming the conductive material layers of the waveguide by evaporation ((page 736, col. 1). Note that thermal

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evaporation is also known in the semiconductor art as evaporation, vapor deposition, sputtering, etc.

6. Claim 10 is rejected under 35 U.S.C. 103(a) as being unpatentable over Hu et al (cited by Applicant) in view of Solon Spiegel (cited by applicant) further in view of Wolf further in view of Tran (US 6,259,407 cited by Applicant).

7. Hu in view of Spiegel further in view of Wolf teaches most aspects of the instant invention except for a conductive material comprising copper. Nonetheless, Tran teaches a method for making a coplanar waveguide including the use of copper for making the waveguide conductive layers (col. 7/lls. 55-60). It would have been obvious to one having ordinary skill in the art at the time the invention was made to use copper to make the conductive layers of the waveguide disclosed by Hu in view of Spiegel further in view of Wolf as suggested by Tran, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. *In re Leshin*, 125 USPQ 416.

Allowable Subject Matter

8. Claims 4-9, 12-44 and 92-110 are allowed.

Response to Arguments

9. Applicant's arguments with respect to claim 1 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Leonardo Andújar whose telephone number is 571-272-

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1912. The examiner can normally be reached on Mon through Thu from 9:00 AM to 7:30 PM EST.

11. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on 571-272-1915. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

12. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



Leonardo Andujar

Patent Examiner Art Unit 2826

LA

07/20/2005